

MICRO-523: Optical Detectors

Week Five: Photodiodes – Exercises

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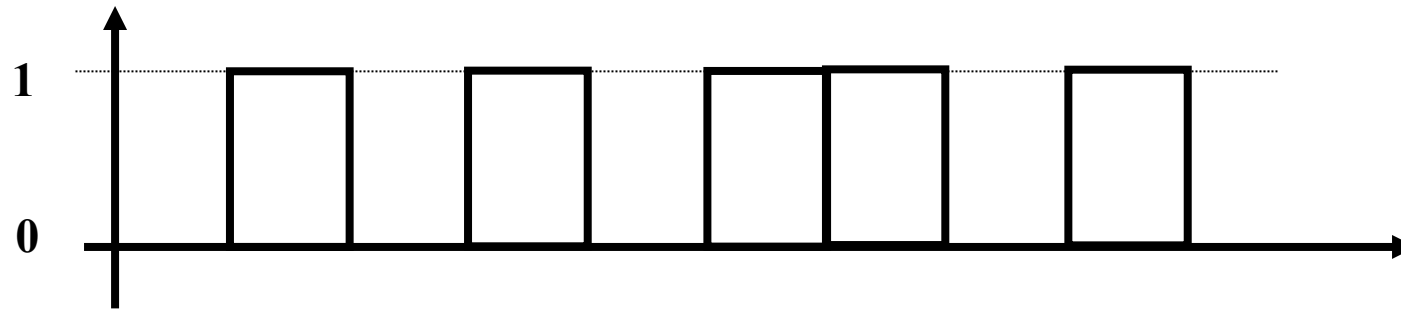


Outline

- 5.1 High-speed photodiodes and BER
- 5.2 PIN Heterostructure Photodiode

Exercise 5.1: High-speed photodiodes and BER

- On-off keying system: bits “0” and “1”

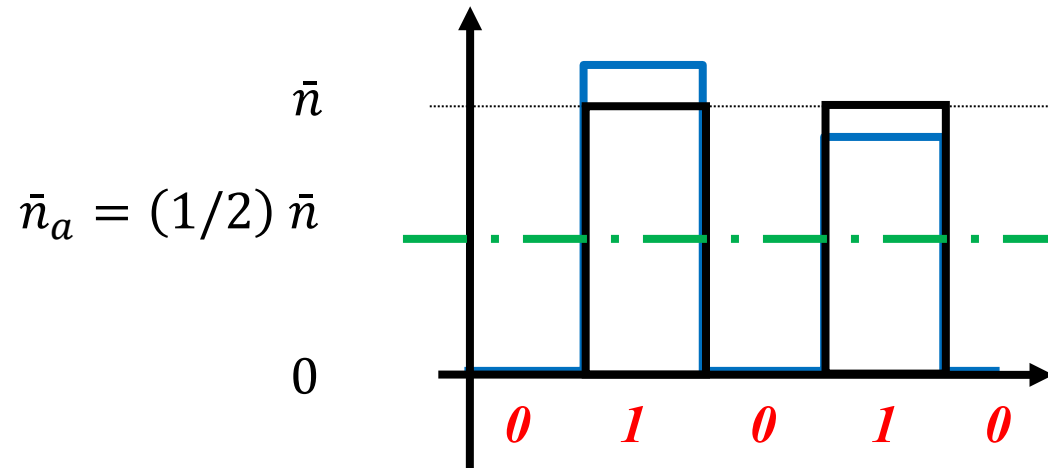


- BER: probability of error per bit
- If p_0 = probability of mistaking a “0” for a “1”
& p_1 = probability of mistaking a “1” for a “0”, then

$$\text{BER} = p_0 / 2 + p_1 / 2 \quad (\text{BER definition})$$

Exercise 5.1: High-speed photodiodes and BER

Ideal = limited by the optical signal shot noise



- If an average of \bar{n} photons is transmitted by a laser diode, the probability of detecting n photons is given by:

$$p(n) = \bar{n}^n \frac{\exp(-\bar{n})}{n!}$$

→ How many photons per “1” bit are needed to guarantee a BER of 10^{-9} ?

Exercise 5.2: PIN Heterostructure Photodiode

In_{1-x}Ga_xAs_yP_{1-y} system on an InP substrate

a) To grow a monocrystal, we have to preserve the lattice of the InP substrate.
This involves satisfying the following relationship:

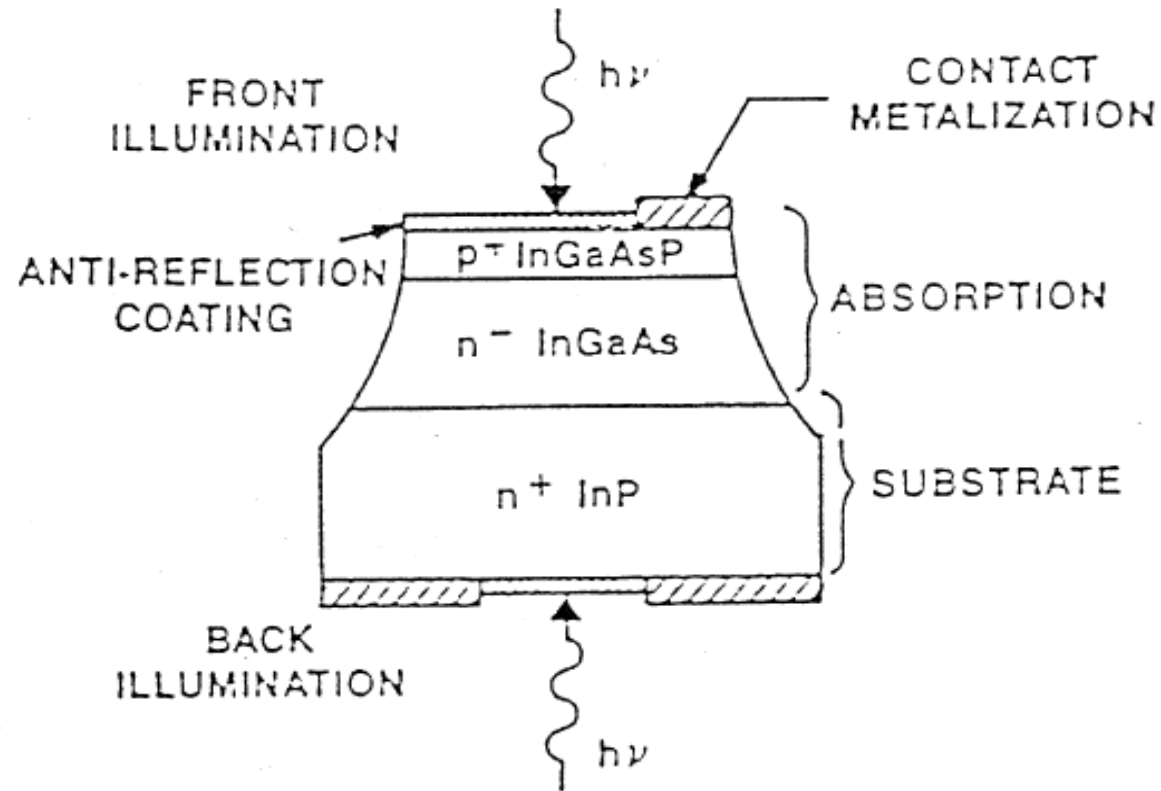
$$x = \frac{0.4562 \cdot y}{1 - 0.031 \cdot y}$$

b) In this case (“lattice matched to InP”) the gap can be changed according to:

$$E_g(y) = 1.35 - 0.72 \cdot y + 0.12 \cdot y^2 \quad [eV]$$

Exercise 5.2: PIN Heterostructure Photodiode

Consider the PIN photodiode depicted below:



Exercise 5.2: PIN Heterostructure Photodiode

This type of photodiode was designed for optical telecommunications and has to work at wavelengths between $1.50\text{ }\mu\text{m}$ and $1.60\text{ }\mu\text{m}$. Its diameter is $10\text{ }\mu\text{m}$, corresponding to that of a single mode fiber optic cable.

- A) Considering a superficial layer with the following composition: $\text{In}_{1-x}\text{Ga}_x\text{As}_y\text{P}_{1-y}$, with $y=0.84$.
Sketch the quantum efficiency for front and back illumination. What is the main difference?
- B) Estimate the width W of the intrinsic InGaAs region to optimize the bandwidth using a load resistance of $R_L = 50\text{ }\Omega$.
(use $\varepsilon = 12$ and $v_{\text{sat}} = 10^5\text{ m/s}$)
Does the diode have to be polarized, and if so, why?